

Support Information

Lattice Vibration of Layered GaTe Single Crystals

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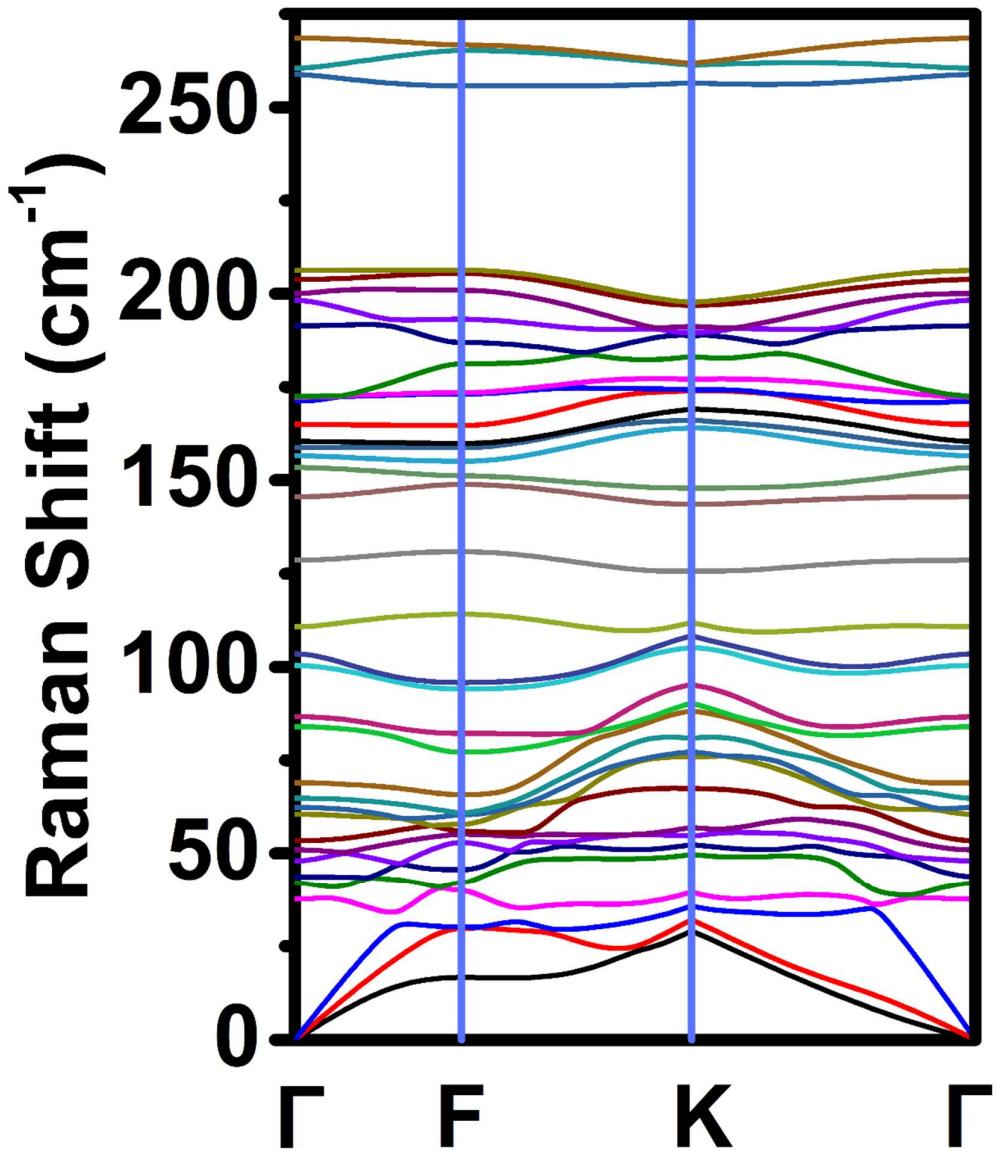


Fig. S1 The calculated Phonon dispersion of GaTe Single crystals.

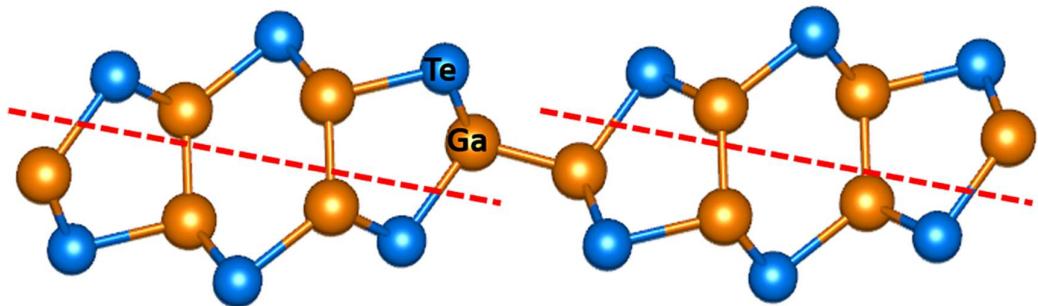


Fig. S2 The direction of axis in GaTe